Supporting Information:

Pressure-Induced Superconductivity in the Charge-Density-

Wave Compound LaTe_{2-x}Sb_x (x = 0 and 0.4)

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Table S1. Summary of selected crystallographic parameters of LaTe₂ under high pressure taken form the Rietveld refinements results (space group P4/nmm, Z = 2, Te(2) (0, 0, 0)).

	0.2 GPa	1.5 GPa	3.1 GPa	4.6 GPa	5.9 GPa	7.3 GPa
<i>a</i> (Å)	4.558 (2)	4.532 (2)	4.501 (2)	4.476 (2)	4.466 (2)	4.450 (2)
<i>c</i> (Å)	9.214 (6)	9.160 (6)	9.091 (6)	9.057 (6)	9.014 (6)	8.993 (6)
<i>V</i> (ų)	191.4 (2)	188.1 (2)	184.2 (2)	181.4 (2)	179.8 (2)	178.1 (2)
R _p (%)	1.10	1.59	1.65	1.65	1.56	1.72
R _{wp} (%)	1.58	2.22	2.19	2.30	2.21	2.47
Atomic sites						
La(1) (0, 0.5, z1)	0.265 (1)	0.276 (1)	0.278 (1)	0.277 (1)	0.276 (1)	0.280 (1)
Te(1) (0, 0.5, z2)	0.647 (1)	0.651 (1)	0.649 (1)	0.649 (1)	0.653 (1)	0.652 (1)
	9.3 GPa	12.0 GPa	15.9 GPa	21.6 GPa	28.5 GPa	34.8 GPa
<i>a</i> (Å)	4.432 (2)	4.418 (2)	4.385 (2)	4.344 (2)	4.286 (3)	4.246 (3)
<i>c</i> (Å)	8.952 (6)	8.895 (6)	8.809 (6)	8.713 (6)	8.583 (7)	8.500 (7)
<i>V</i> (ų)	175.8 (2)	173.6 (2)	169.4 (2)	164.4 (2)	157.6 (3)	153.2 (3)
R _p (%)	1.39	1.30	1.58	1.80	1.84	2.76
R _{wp} (%)	2.04	1.95	2.48	2.82	3.03	4.52
Atomic sites						
La(1) (0, 0.5, z1)	0.281 (1)	0.278 (1)	0.269 (1)	0.267 (1)	0.268 (1)	0.270 (1)
Te(1) (0, 0.5, z2)	0.649 (1)	0.647 (1)	0.646 (1)	0.647 (1)	0.648 (1)	0.657 (1)



Figure S1. The $R/R_{4K/5K/6K}$ around T_c under external magnetic fields of LaTe₂ at different pressures.



Figure S2. Hall resistivity (*R*-*H*) at 100 K of LaTe₂.



Figure S3. Hall resistivity (*R*-*H*) at 100 K of LaTe_{1.6}Sb_{0.4}.



Figure S4. Hall coefficients of LaTe_{1.6}Sb_{0.4}.